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Dkt. No.: 67493/63

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants : Patrick M. Martin et al. Confirmation No.: 2002
Serial No. : 10/658,039
Filing Date: : September 9, 2003
For : PHOTOMASK HAVING AN INTERNAL SUBSTANTIALLY
TRANSPARENT ETCH STOP LAYER
Art Unit : 1756
Examiner : Stephen D. Rosasco
Docket No. : 67493/63
Customer No. : 1912

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Date of Deposit:	FEBRUARY 18, 2005
I hereby certify that this paper or fee is being deposited with the United States Postal Service "Express Mail" service under 37 CFR 1.10 on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.	
Name:	Vivian Campbell
Signature:	<i>Vivian Campbell</i>

SUBMISSION OF INFORMATION DISCLOSURE STATEMENT

MAIL STOP: AMENDMENT
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22323-1450

Sir:

Pursuant to 37 C.F.R. §§§ 1.56, 1.97 and 1.98, applicant encloses herewith form PTO/SB/08A containing references which may be deemed relevant to the above-identified application.

We also enclose copies of Japanese patent documents with corresponding English Abstracts. JP-8-75353 is submitted in Japanese with its English translation and Abstract.

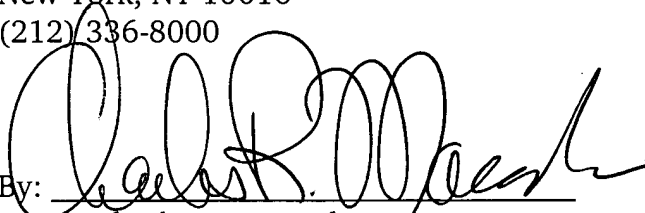
The Examiner is respectfully requested fully to consider the enclosed items, and independently assess their teachings.

No fee is deemed necessary in connection with the filing of this Information Disclosure Statement. If any fee is required to preserve the pendency of the application, authorization is hereby given to charge the amount of any such fee to deposit Account No. 01-1785.

Respectfully submitted,

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Dated: February 18, 2005
New York, New York

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